

Notice of References Cited

Application/Control N 09/670,520 Examiner

Applicant(s)/Patent Under Reexamination MORIYAMA ET AL.

Art Unit

2825

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U.S. PATENT DOCUMENTS

Granvill D Lee, Jr

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6153469	07-1999	Yun et al.	438/257
	В	US-5880498	07-1997	Kinoshita et al.	257/315
	O	US-6037221	02-1997	Lee et al.	438/257
	۵	US-5587332	09-1992	Chang et al.	437/43
	Ε	US-6063662	·12-1997	Bui	438/257
	F	US-6335549	03-1996	Kusunoki et al.	257/231
	G	US-2001/0040252	12-1997	Kobayashi et al.	257/314
	Н	US-6100559	08-1998	Park ,	257/315
	1	US-4409723	09-1980	Harari	29/571
	J	US-5663084	05-1995	Yi et al.	438/453
	К	US-6255167	06-1999	Wu	438/259
	L	US-6093604	02-1998	Jeong	438/257
	М	US-4789560	01-1986	Yen	427/96

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
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NON-PATENT DOCUMENTS

	NON-I ATENT BOOMENTO				
*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)			
	U	Rama et al. "Growth and surface chemistry of oxynitride gate dielectric using nitric oxide" Appl. Phys. Lett vol. 66 #21 may 1995 pg. 2882-84.			
	v				
	w	·			
	х				

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

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